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PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Takuya MONJU et al.

Group Art Unit: 1774

Application No.: 09/411,322

Examiner: B. Shewareged

Filed: October 4, 1999

Docket No.: 104472

For: THERMAL TRANSFER RECORDING MEDIUM

AMENDMENT

RECEIVED

SEP 14 2001

TC 1700

Director of the U.S. Patent and Trademark Office
Washington, D.C. 20231

Sir:

Due to the Patent Office closure on September 11, 2001, this response is being filed on September 12, 2001, the next business day. In reply to the Office Action mailed April 11, 2001, please amend the above-identified application as follows:

IN THE CLAIMS:

Please replace claims 1 and 11 as follows:

- sub
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A1
1. (Amended) A thermal transfer recording medium comprising:
- a substrate in the form of a film;
 - a solvent-resistant layer formed on said substrate by applying a composition comprising a dispersion of polyethylene wax in a solvent and a solution of polyester resin in a solvent; and
 - an ink layer formed by coating on said solvent-resistant layer, the ink layer comprising a ketone resin.
- A2
sub
cl
11. (Amended) A thermal transfer recording medium according to Claim 4, wherein a release layer is formed between said substrate and said solvent-resistant layer.